



Standard Practice for Microetching Metals and Alloys¹

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This standard has been approved for use by agencies of the U.S. Department of Defense.

^{ε1} NOTE—Originally approved date was editorially corrected to 1970 in footnote 1 in January 2016.

1. Scope

1.1 This practice covers chemical solutions and procedures to be used in etching metals and alloys for microscopic examination. Safety precautions and miscellaneous information are also included.

1.2 *This standard does not purport to address all of the safety concerns, if any, associated with its use. It is the responsibility of the user of this standard to establish appropriate safety and health practices and determine the applicability of regulatory limitations prior to use.* For specific cautionary statements, see 6.1 and Table 2.

2. Referenced Documents

2.1 *ASTM Standards:*²

D1193 Specification for Reagent Water

E7 Terminology Relating to Metallography

E2014 Guide on Metallographic Laboratory Safety

3. Terminology

3.1 *Definitions:*

3.1.1 For definition of terms used in this standard, see Terminology E7.

3.2 *Definitions of Terms Specific to This Standard:*

3.2.1 *tint etch*—an immersion etchant that produces color contrast, often selective to a particular constituent in the microstructure, due to a thin oxide, sulfide, molybdate, chromate or elemental selenium film on the polished surface that reveals the structure due to variations in light interference effects as a function of the film thickness (also called a "stain etch").

3.2.2 *vapor-deposition interference layer method*—a technique for producing enhanced contrast between microstructural constituents, usually in color, by thin films formed by vacuum deposition of a dielectric compound (such as ZnTe, ZnSe, TiO₂, ZnS or ZnO) with a known index of refraction, generally due to light interference effects (also known as the "Pepperhoff method").

4. Summary of Practice

4.1 Table 1 is an alphabetical listing of the metals (including rare earths) and their alloys for which etching information is available. For each metal and alloy, one or more etchant numbers and their corresponding use is indicated. Alloys are listed as a group or series when one or more etchants are common to the group or series. Specific alloys are listed only when necessary. When more than one etchant number is given for a particular use, they are usually given in order of preference. The numbers of electrolytic etchants are *italicized* to differentiate them from nonelectrolytic etchants.

4.2 Table 2 is a numerical listing of all the etchants referenced in Table 1 and includes the composition and general procedure to be followed for each etchant.

4.3 To use the tables, look up the metal or alloy of interest in Table 1 and note the etchant numbers corresponding to the results desired. The etchant composition and procedure is then located in Table 2 corresponding to the etchant number.

4.4 If the common name of an etchant is known (Marble's, Vilella's, etc.), and it is desired to know the composition, Table 3 contains an alphabetical listing of etchant names, each coded with a number corresponding to the etchant composition given in Table 2.

5. Significance and Use

5.1 This practice lists recommended methods and solutions for the etching of specimens for metallographic examination. Solutions are listed to highlight phases present in most major alloy systems.

6. Safety Precautions

6.1 Before using or mixing any chemicals, all product labels and pertinent Material Safety Data Sheets (MSDS) should be

¹ This practice is under the jurisdiction of ASTM Committee E04 on Metallography and is the direct responsibility of Subcommittee E04.01 on Specimen Preparation.

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² For referenced ASTM standards, visit the ASTM website, www.astm.org, or contact ASTM Customer Service at service@astm.org. For *Annual Book of ASTM Standards* volume information, refer to the standard's Document Summary page on the ASTM website.